IN THE CLAIMS

Please cancel claim 14 without prejudice. Please amend the following claims

which are pending in the present application:

1. (Currently Amended) A thermal interface material for thermal coupling of an

electronic component to a thermally conductive member, comprising:

a viscoelastic polymer matrix material; and

fusible solder particles in the matrix material, having a melting temperature

below a selected temperature of 300°C; and

filler particles in the matrix material, having a melting temperature above the

selected temperature.

2. (Original) The thermal interface material of claim 1 wherein the matrix material

comprises between 1 and 20% by weight.

3. (Original) The thermal interface material of claim 2 wherein the matrix material

comprises approximately 8% by weight.

4. (Original) The thermal interface material of claim 1 wherein the matrix material

is selected from the group consisting of a silicone, an amino epoxy, and acrylate, an

olifin resin, a low-viscosity vinyl and a phase-change material.

Examiner: Ahmed, Sheeba Application No.: 10/038,334 - 2 -Art Unit: 1773

5. (Original) The thermal interface material of claim 4 wherein the matrix material

is silicone.

6. (Original) The thermal interface material of claim 5 wherein the solder

particles comprise between 1 and 99% by weight.

7. (Original) The thermal interface material of claim 6 wherein the solder

particles comprise at least 5% by weight.

8. (Original) The thermal interface material of claim 7 wherein the solder

particles comprise between 25 and 90% by weight.

9. (Original) The thermal interface material of claim 1 wherein the solder

particles are selected from the group consisting of In, InSn, InAg, SnAg, SnAgCu,

SnBi, InSnBi, InTi, InZr, InTiCeSe, and InAgTiSeCe.

10. (Original) The thermal interface material of claim 1 wherein the matrix material

is silicone and the solder particles do not substantially attack the silicone when the

solder particles melt.

(Original) The thermal interface material of claim 1 wherein the solder

particles have a melting temperature between 60 and 300°C.

- 3 -

12. (Original) The thermal interface material of claim 11 wherein the solder

particles have a melting temperature of approximately 15/°C.

13. (Original) The thermal interface material of claim 1 wherein the solder

particles have widths of between 0.2 and 100 microns.

14. (Canceled)

15. (Currently Amended) The thermal interface material of claim [[14]] 1 wherein

the filler particles comprise between 1 and 95% of the thermal interface material by

weight.

16. (Original) The thermal interface material of claim 15 wherein the filler particles

comprise at least 10% by weight.

17. (Original) The thermal interface material of claim 16 wherein the filler particles

comprise approximately 15% by weight.

18. (Original) The thermal interface material of claim 16 wherein the solder

particles and the filler particles comprise between 50 and 95% by weight.

19. (Original) The thermal interface material of claim 18 wherein the solder

particles and the filler particles comprise approximately 92% by weight.

Examiner: Ahmed, Sheeba

-4-

Art Unit: 1773

20. (Original) The thermal interface material of claim 16 wherein the tiller particles

are selected from the group consisting of Ni, Cu, Ag, Ag/Cu, Sn, graphite and Al.

21. (Original) The thermal interface material of claim 20 wherein the filler particles

are Al.

22. (Original) The thermal interface material of claim 16 wherein the filler particles

have a melting temperature above 350°C.

23. (Original) The thermal interface material of claim 16 wherein the filler particles

have a melting temperature which is at least 100°C above a melting temperature of

the solder particles.

24. (Original) The thermal interface material of claim 16 wherein the filler particles

have a melting temperature which is at least 200°C above a melting temperature of

the solder particles.

25. (Original) A thermal interface material for thermal coupling of an electronic

component to a thermally conductive member, comprising:

a viscoelastic polymer matrix material;

fusible solder particles in the matrix material, having a melting temperature

below 200°C and do not substantially attack the matrix material when the solder

- 5 -

particles are melted; and

filler particles in the matrix material, having a melling temperature above

400°C.

26. (Original) The thermal interface material of claim 25 wherein the matrix

material is silicone.

27. (Original) The thermal interface material of claim 26 wherein the filler particles

are aluminum.

28. (Original) An electronic assembly comprising:

an electronic component which generates heat when operated;

a thermally conductive member spaced from the electronic component; and

a thermal interface material between the electronic component and the

thermally conductive member, the thermal interface material including a viscoelastic

polymer matrix material, solder particles that are fused together so as to provide an

unbroken thermal path for heat to conduct from the electronic component and the

thermally conductive member and having a melting temperature below a selected

temperature, and filler particles in the matrix material having a melting temperature

above the selected temperature.

- 29. (Original) The electronic assembly of claim 28 wherein the filler particles have a melting temperature which is at least 100°C above a meiting temperature of the solder particles.
- 30. (Original) The electronic assembly of claim 29 wherein at least one of the filler particles is in contact with and entirely surrounded by one of the solder particles.

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Application No.: 10/038,334

Examiner: Ahmed, Sheeba

Art Unit: 1773